IFW



In re the Application of: Shun-ichi FUKUYAMA et al. Group Art Unit: 2813

Serial No.: 10/630,716 Examiner: Stephen W. Smoot

Filed: July 31, 2003 Confirmation No.: 9374

For: SEMICONDUCTOR DEVICE USING LOW-K MATERIAL AS

INTERLAYER INSULATING FILM AND ITS MANUFACTURE

METHOD

Attorney Docket Number: 030860

Customer Number: 38834

AMENDMENT UNDER 37 CFR § 1.111

Mail Stop Amendment

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

November 15, 2004

Sir:

In response to the Office Action dated August 26, 2004, applicants amend the aboveidentified application as follows and submits the following remarks.

Amendments to the Claims are reflected in the listing of claims that begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.